

EAST Search History**EAST Search History (Interference)**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	1	(method forming electronic device multilayer structure comprising embossing surface substrate depress first second regions substrate relative least third region substrate treating surface modification process different effect depressed non- depressed given different surface energies deposition material depositing conductive semiconductive material solution electrode electrically insulated ridge width length channel).clm.	US- PGPUB; USPAT; UPAD	AND	ON	2010/12/15 15:33

12/ 15/ 2010 3:35:29 PM
**C:\Documents and Settings\dgraybill\My Documents\EAST\Workspaces\10538857.
wsp**